IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

FEB 2 3 20

P.K In re Application of:

Gurtej S. Sandhu

Serial No.: 09/023,146

Filed: February 12, 1998

For: TUNGSTEN SILICIDE (WSIx)

DEPOSITION PROCESS FOR

SEMICONDUCTOR MANUFACTURE

Examiner: T. Dang

Group Art Unit: 2823

Attorney Docket No.: 3369.1US

(91-365-RE)

I hereby certify that this correspondence along with any attachments referred to or identified as being attached or enclosed is being deposited with the United States Postal Service as First Class Mail (under 37 C.F.R. § 1.8(a)) on the date of deposit shown below with sufficient postage and in an envelope addressed to the Assistant Commissioner for Patents, Washington, D.C. 20231.

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Devin R. Jensen

Typed/printed name of person whose signature is contained above

AMENDMENT UNDER 37 C.F.R. §1.116

Box AF Commissioner for Patents Washington, D.C. 20231

Sir:

The following remarks are filed in response to the Examiner's remarks in the Final Office Action mailed December 20, 2000, the three-month shortened statutory period for response to which expires on March 20, 2000. This response is submitted on or before two months from the mailing date of the Final Office Action.

CERTIFICATE OF MAILING